

Supplementary Information

Enhanced vapor sorption in block and random copolymer brushes

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1 Difference in sorption upon changing ϵ_{ab}

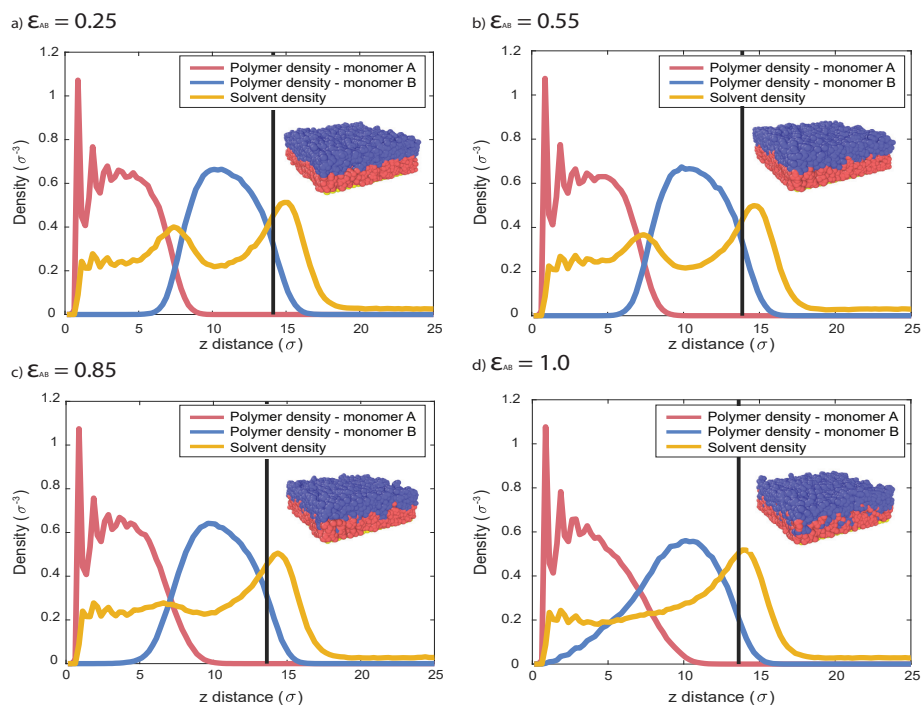


Figure SI 1: Monomer A (purple), monomer B (blue) and solvent (yellow) density profiles at different monomer cross-interaction strengths (ϵ_{ab}). At $\epsilon_{ab} = 1$, the peak correlated to excess solvent disappears due to the mixing of monomers (SI1d). In all simulations we keep $\epsilon_{pp} = \epsilon_{ss} = \epsilon_{ps} = 1$.

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2 Alternating brush

We perform additional simulations of an alternating brush (-A-B-A-B-) to investigate the enhanced sorption effect. Even though the alternating brush contains the most A-B interfacial contacts, it does not sorb considerably more vapor than a random brush. To show this, we plot solvent density profiles at $\epsilon_{ab} = 0.4, 0.7$ and 1.0 of an alternating and random brush in Fig. SI 2. Qualitatively, solvent profiles are similar in shape and area. Quantitatively, the difference of solvent sorbed is 0.6% at $\epsilon_{ab} = 0.4$, 0.4% at $\epsilon_{ab} = 0.7$, and 0.5% at $\epsilon_{ab} = 1.0$. These values are obtained by integrating the areas below the solvent profiles. Therefore, we conclude that there is a negligible difference in vapor sorption between an alternating and random brush.

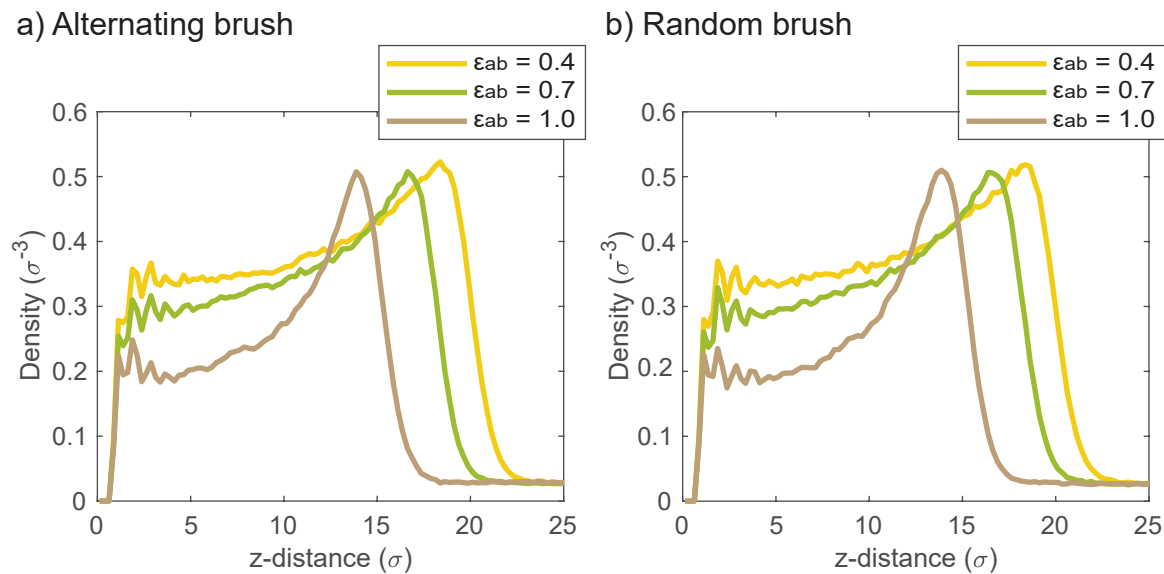


Figure SI 2: Solvent density profiles at different ϵ_{ab} of a) an alternating brush, and b) a random brush. Other particle-particle interactions are kept constant ($\epsilon_{pp} = \epsilon_{ps} = \epsilon_{ss} = 1$).

3 The same particle-particle interactions - the same polymer density profiles

We perform simulations of a pure homopolymer brush and a 2-block brush while maintaining all particle-particle interactions to be 1. When simulating a pure homopolymer brush this means: $\epsilon_{pp} = \epsilon_{ps} = \epsilon_{ss} = 1$. When simulating a 2-block brush, this means: $\epsilon_{ab} = \epsilon_{pp} = \epsilon_{ps} = \epsilon_{ss} = 1$. We observe that the pure brush density profile overlaps with the sum of 2-block brush density profile (sum polymer density A and polymer density B). The polymer density profiles are identical since the particle interactions are identical, as shown in Figure SI 3.

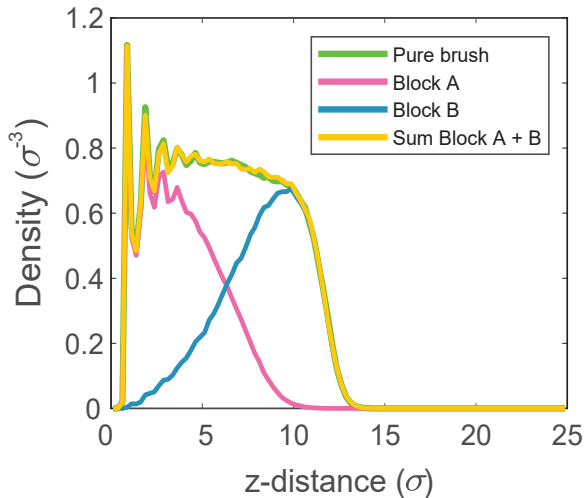


Figure SI 3: Polymer density profile of a pure homopolymer brush (green) and a sum of density profiles in a 2-block brush, A + B, shown in yellow. The profiles are identical since all particle-particle interactions are identical. $\epsilon_{xx} = 1$